

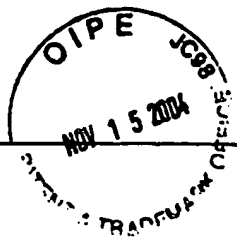
**INFORMATION DISCLOSURE
STATEMENT BY APPLICANT**
Form PTO/SB/08a

Application Number	10/820,732
Filing Date	April 9, 2004
First Named Inventor	Toshiharu TANAKA et al.
Art Unit	3653
Examiner Name	
Attorney Docket Number	107350-00008

Sheet	1	of	1
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[illegible][illegible]Date
Considered

TECH/335449.1



Sheet 1 of 1

FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO.

107350-00008

SERIAL NO.

10/820,732

LIST OF REFERENCES CITED BY APPLICANT

(Use several sheets if necessary)

APPLICANT

TANAKA et al.

FILING DATE

April 9, 2004

GROUP

3653

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
PJ	AA	5,831,272					
	AB						
	AC						
	AD						
	AE						
	AF						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUB- CLASS	TRANSLATION YES NO PART.		
	AG								
	AH								
	AI								
	AJ								
	AK								
	AL								

OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)

PJ	AM	NOZUE et al., "Development of Next-Generation Electron-Beam Exposure Systems", OYO BUTURI, Vol. 71, No. 4, pp. 421-424 (2002).
	AN	
	AO	

EXAMINER /Phillip Johnston/ (12/15/2006)

DATE CONSIDERED

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.